



United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/069,668	04/29/1998	KIE Y. AHN	303.466US1	3628	
21186	7590 05/22/2002				
SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.			EXAMINER		
P.O. BOX 293	· -	COLEMAN, WILLIAM D			
MINNEAPOL	LIS, MN 55402		COLEMAN, WILLIAM D		
			ART UNIT	PAPER NUMBER	
			2823		
			DATE MAILED: 05/22/2002	DATE MAILED: 05/22/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

,				- Um
,		Application No.	Applicant(s)	
Office Action Summary		09/069,668	AHN ET AL.	
		Examiner	Art Unit	
	The MAN INC DATE - CALL	W. David Coleman	2823	
Period fo	The MAILING DATE of this communication or or Reply	appears on the cover sheet wit	h the correspondence addre	ss
- Exte after - If the - If NC - Failu - Any I	ORTENED STATUTORY PERIOD FOR REI MAILING DATE OF THIS COMMUNICATION ensions of time may be available under the provisions of 37 CFR SIX (6) MONTHS from the mailing date of this communication. It is period for reply specified above is less than thirty (30) days, a period for reply is specified above, the maximum statutory perior to reply within the set or extended period for reply will, by state to reply within the set or extended period for reply will, by state to reply within the set or extended period for reply will, by state to period by the Office later than three months after the material patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a re- reply within the statutory minimum of thirty od will apply and will expire SIX (6) MONT	oly be timely filed (30) days will be considered timely. HS from the mailing date of this comm	unication.
1)🖂	Responsive to communication(s) filed on 1	<u> 2 February 2002</u> .		
2a)⊠	This action is FINAL . 2b)	This action is non-final.		
3) Dispositi	Since this application is in condition for allo closed in accordance with the practice und ion of Claims	wance except for formal matter er <i>Ex parte Quayle</i> , 1935 C.D	ers, prosecution as to the m . 11, 453 O.G. 213.	nerits is
4)🖂	Claim(s) 1-28 and 32-38 is/are pending in t	he application.		
	4a) Of the above claim(s) <u>29 and 30</u> is/are w	ithdrawn from consideration.		
5)	Claim(s) is/are allowed.			
6)⊠	Claim(s) 1-28 and 32-38 is/are rejected.			
7)	Claim(s) is/are objected to.			
	Claim(s) are subject to restriction and on Papers	l/or election requirement.		
9) 🗆 -	The specification is objected to by the Exami	ner.		
10) 🔲 🗆	The drawing(s) filed on is/are: a)□ ac	cepted or b) objected to by the	Examiner.	
	Applicant may not request that any objection to			
11) 🔲 🗆	The proposed drawing correction filed on		* *	
	If approved, corrected drawings are required in			
12) 🔲 7	The oath or declaration is objected to by the ${ t I}$	Examiner.		
Priority u	ınder 35 U.S.C. §§ 119 and 120			
13)	Acknowledgment is made of a claim for fore	ign priority under 35 U.S.C. §	119(a)-(d) or (f).	
1	☐ All b)☐ Some * c)☐ None of:	•	.,,,,	
	1. Certified copies of the priority docume	nts have been received.		•
	2. Certified copies of the priority docume	nts have been received in App	olication No.	
	3. Copies of the certified copies of the prapplication from the International Elee the attached detailed Office action for a lie	iority documents have been re Bureau (PCT Rule 17.2(a)).	eceived in this National Sta	ge
	cknowledgment is made of a claim for dome	•		alication)
_a)	The translation of the foreign language packnowledgment is made of a claim for dome	provisional application has bee	en received.	nication).
Attachment		and priority under 35 U.S.C. 9	3 120 and/or 121.	
1) Notice 2) Notice 3) Inform	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Inf	mmary (PTO-413) Paper No(s) ormal Patent Application (PTO-15)	
U.S. Patent and Tra PTO-326 (Rev		Action Summary	Part of Pape	er No. 20

Art Unit: 2823

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, 2, 3, 4, 5, 7, 8, 9, 10, 11, 28, 32, 33, 35, 36, 37 and 38 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsai, U.S. Patent 5,235,204 in view of Wolf, "Silicon Processing For The VLSI ERA", vol. 2 (Process Integration), Lattice Press, 1990, pp. 116-117 & 126-127.
- 3. Pertaining to claims, 1, 4, 5, 7, 8, 9, 10, 28, 35, 36, 37, 38 and 39, <u>Tsai</u> discloses a semiconductor process substantially as claimed. See **FIG. 6**, where a method of making an emitter contact for an emitter region of a bipolar transistor is disclosed. <u>Tsai</u> discloses a polysilicon structure **60** over an emitter region position of a semiconductive substrate (not numbered). However, the metal emitter contact is not formed by cross diffusing the metal and a portion of the polysilicon structure. <u>Wolf</u> teaches the use of a doped polysilicon sacrificial barrier in the fabrication of contacts and interconnects (pp. 126). A thin layer of doped polysilicon can be used to separate the Al and the single-crystal Si substrate (Fig. 3-28). After the Al:Si alloy film as been patterned, the contact structure is annealed (pp.127). In view of <u>Wolf</u>, it would have been obvious to one of ordinary skill in the art to form the metal emitter contact of <u>Tsai</u> by cross diffusing the metal and a portion of the polysilicon structure, because this process alleviates the problem of junction spiking (pp. 116).

Art Unit: 2823

Page 3

- 4. Pertaining to claim 2, <u>Tsai</u> discloses an emitter region 40 as seen in **FIG. 6**. However, in the absence of new or unexpected results, the mere reversal of the order of performing process steps has been held to be prima facie obvious. In re Burhans, 154 F.2d 690, 69 USPQ 330 (CCPA 1946).
- 5. Pertaining to claim 3, <u>Tsai</u> discloses that the emitter region 40 is polysilicon and metallurgy level being aluminum, which is obviously a doped layer (p-type) that will outdiffuse into the polysilicon region when annealed.
- 6. Pertaining to claim 11, <u>Tsai</u> discloses that the metal layer 64, can be aluminum. Claim 6 is rejected under 35 U.S.C. 103(a) as being unpatentable over Tsai, U.S. Patent 5,235,204 in view of Wolf, "Silicon Processing For The VLSI ERA", vol. 2 (Process Integration), Lattice Press, 1990, pp. 116-117 & 126-127, as applied to claims 1-3 and 7-11 above, and further in view of Aboelfotoh et l., U.S. Patent 5,801,444.
- 7. The combined teachings of <u>Tsai</u> in view of <u>Wolf</u> discloses a semiconductor process substantially as claimed as discussed above. However <u>the combined teachings</u> fail to disclose a polysilicon layer that includes polysilicon and germanium. <u>Aboelfotoh</u> discloses a semiconductor process wherein germanium is included with silicon for the purpose of making electrical contacts. See **FIG. 11** of Aboelfotoh, where germanium (11) is deposited with polysilicon for the purposes of a contact for a semiconductor device. In view of <u>Aboelfotoh</u> it would have been obvious to one of ordinary skill in the art to include germanium with polysilicon for contact formation because a substantial advantage to be gained is that electrically stable contact metallization (column 5, lines 49-51).

Art Unit: 2823

Claim Rejections - 35 USC § 112

Page 4

8. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

9. Claims 1-28 and 32-39 recites the limitation "metal" in independent claims 1, 4, 6,12, 18,

20, 23 28, 32, 33 and 35. There is insufficient antecedent basis for this limitation in the claim.

Correction is required.

Conclusion

- 10. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).
- 11. A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.
- 12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to W. David Coleman whose telephone number is 703-305-0004. The examiner can normally be reached on 9:00 AM-5:00 PM.

Art Unit: 2823

Any inquiry concerning this communication or earlier communications from the 12.

examiner should be directed to W. David Coleman whose telephone number is 703-305-0004.

Page 5

The examiner can normally be reached on 9:00 AM-5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Wael M. Fahmy can be reached on 703-308-4918. The fax phone numbers for the

organization where this application or proceeding is assigned are 703-308-7722 for regular

communications and 703-308-7721 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is 703-308-0956.

WDC May 15, 2002